

# Supply Chain Explorer: Etch and clean

This is an export from the Emerging Technology Observatory **Supply Chain Explorer** (<https://chipexplorer.eto.tech>). You can see the web version of this content at <https://chipexplorer.eto.tech/?filter-choose=input-resource&input-resource=N46>.

## Etch and clean

After photolithography creates a pattern in the photoresist coating a wafer, specialized tools etch the pattern into the permanent layer below the photoresist. The photoresist is then removed and the etched material cleaned off of the layer.